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溶融塩中における酸化シリコンの融体構造

Melting Structure of Silicon Dioxide in Molten Salts

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Many studies¹⁻³⁾ related to in-situ resource utilization (ISRU) have been conducted to separate and recover useful elements such as silicon from lunar regolith by molten salt electrolysis. Since SiO₂ is the main component of lunar regolith, it is beneficial to fabricate polycrystalline silicon films from SiO₂ on the moon as a material for solar cells. In the molten salt electrolysis, the solubility behavior of SiO₂ and electrochemical behavior of silicon ion is dependent on the composition of molten salt. Hence the understanding of the interactions between silicon ion formed by dissolving SiO₂ and constituent ions of the melt is important to control the solubility process of SiO₂ and the silicon electrodeposition process. Therefore, in this study⁴⁻⁵⁾, we report the melting structure of SiO₂ in fluoride melts, whose bath have several advantages, especially the ability to obtain crystalline silicon directly from SiO₂ at lower temperatures because of high solubility of oxides, by combining Raman spectroscopy and DFT calculation.

We investigated melt structures of eutectic LiF-KF, LiF-NaF and NaF-KF adding SiO₂ through Raman spectroscopy and density functional theory calculations. The interactions between silicon ion and constituent ions of the fluoride melts have been identified. A good agreement was observed between the calculated and experimental Raman spectra for the melts. The spectra were characterized by two kinds of coordination structures: ion-like structure such as SiF₂O₂²⁻ and Si₂O₅²⁻; and molecule-like structure such as SiF₃O-Li and SiF₂O₂-2Li (**Fig.1**). Moreover, when Li₂O as a source of O²⁻ was added, remarkable bands appeared which were attributed to ion-like structure of SiFO₃³⁻ and SiF₃O⁻, indicating that O²⁻ ions have potential to promote the formation of oxyfluoride monomers by cleaving the Si-O-Si bands of Si₂O₅²⁻ ions or SiO₂. The information for the coordination structure around silicon ion in the fluoride melts are important towards electrodeposition process of silicon films from lunar regolith in terms of designing the electrolyte.

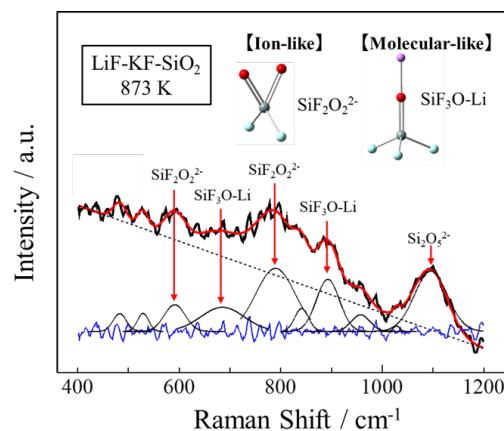


Fig. 1 Raman spectra of LiF-KF melt adding 5.0 mol% SiO₂. Raw data (black bold line), fitting curve (red line), base line (dotted line), residual curve (blue line) and separated bands (black lines). The inserted molecular models are optimized structures of silicon oxyfluoride monomers by DFT calculations.

References

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